

PHOTORESIST COATING SYSTEM

Abstract

The present invention discloses a photoresist coating system. The photoresist coating system mainly includes a chemical tank for positioning at least one photoresist bottle that is used for storing photoresist solution supplied to the photoresist coating system, a cooling system for chilling the photoresist solution in the photoresist bottle to a low temperature, a heating system for heating the photoresist solution transferred from the photoresist bottle to an adequate temperature, and an automatic photoresist feed system for draining and delivering the photoresist solution.